

(19)



Europäisches Patentamt  
European Patent Office  
Office européen des brevets

(11) Publication number:

**0 373 615**  
**A3**

(12)

## EUROPEAN PATENT APPLICATION

(21) Application number: 89123015.3

(51) Int. Cl.<sup>5</sup>: H01F 10/14, H01F 10/18

(22) Date of filing: 13.12.89

(30) Priority: 15.12.88 JP 317475/88  
16.12.88 JP 319089/88  
06.10.89 JP 262405/89  
06.10.89 JP 262406/89

(43) Date of publication of application:  
20.06.90 Bulletin 90/25

(84) Designated Contracting States:  
DE FR GB

(88) Date of deferred publication of the search report:  
17.10.90 Bulletin 90/42

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(54) Soft magnetic alloy films and the method of manufacturing the same.

(57) A nitrogen-containing Fe-based soft magnetic alloy suitable for use as the material of a magnetic head core, as well as a method for manufacturing the soft magnetic alloy film. Unlike a mere nitride alloy film, the soft magnetic alloy of the present invention has a compositionally modulated structure in which at least the nitrogen content is periodically modulated in the direction of thickness of the film so as to have a nitride layer rich at least in nitrogen and a non-nitride layer poor at least in nitrogen. The soft magnetic alloy film of the invention comprises a main constituent of Fe, at least one metalloid element selected from the group consisting of B, Si and C, and at least one metal element selected from the group consisting of Nb, Ta, Zr and Ti and has fine Fe-based grains included therein. By virtue of these film structure and film composition, the soft magnetic alloy film of the invention exhibits superior magnetic characteristics such as low coercive force, high saturation magnetization and low magnetostriction, as well as superior resistance both to corrosion

and wear. The method of the invention is for forming the soft magnetic alloy of the invention, and has the steps of forming by sputtering a compositionally modulated nitride alloy film, and then effecting on the compositionally modulated nitride alloy film a high-temperature heat treatment so as to cause a change in a film structure to form the soft magnetic alloy film.

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# EUROPEAN SEARCH REPORT

Application Number

EP 89 12 3015

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 5)
X	EP-A-0 174 144 (HITACHI) * Page 3, lines 5-19; page 10, lines 6-15, 20-24; page 12, lines 4-18; page 18, lines 2-9; page 19, line 22 - page 20, line 4; claim 8; figures 7a,b *	1	H 01 F 10/14 H 01 F 10/18
A	---	3,4,6,7	
X	PATENT ABSTRACTS OF JAPAN, vol. 13, no. 132 (E-736)[3480], 31st March 1989, page 95 E 736; & JP-A-63 299 219 (SONY CORP.) 06-12-1988 * Whole document *	1	
A	IDEM	2-8	
A	DE-A-3 707 522 (MATSUSHITA) * Page 7, table 1; page 8, lines 46-48; page 9, lines 1-46, 55-57; claims 1-3; figures 4a,b *	1-9	
X,P	EP-A-0 288 316 (MATSUSHITA) * Page 3, lines 58-65; page 4, lines 32-40; page 11, example 6; page 13, line 53 - page 14, line 34; figure 1b; claims 7-12 *	1-8	TECHNICAL FIELDS SEARCHED (Int. Cl. 5)  H 01 F
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 25-07-1990	Examiner KLOCKE S.
<b>CATEGORY OF CITED DOCUMENTS</b> X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document  T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons  & : member of the same patent family, corresponding document			

